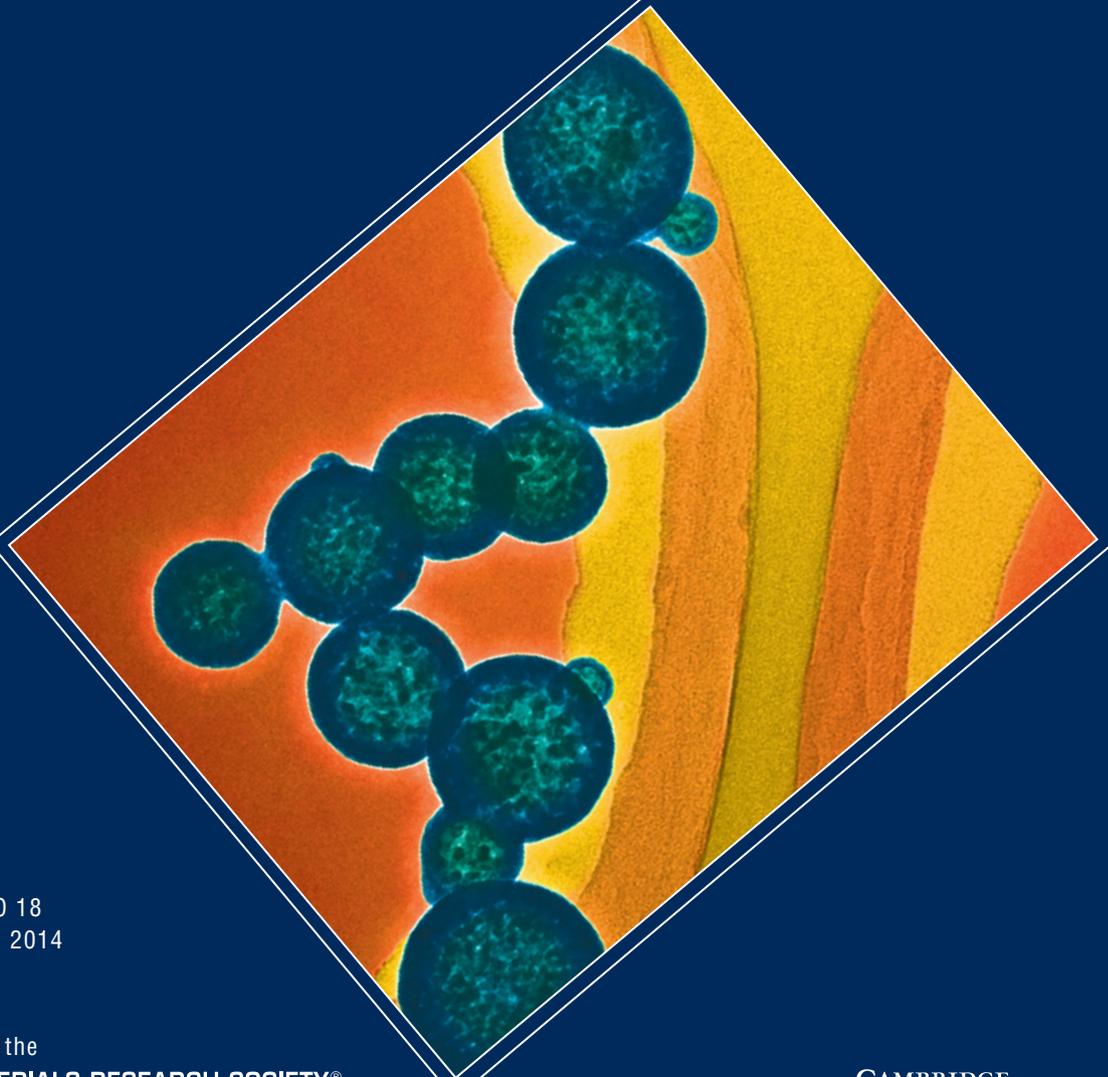




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Cover: FIG. 1(b). The TEM images of $\text{MnO}_x\text{-CeO}_2$ prepared through SAS with PVP. [M. Zhang, H. Jiang, H. Wang, L. Kuang, and G. Li: Synthesis of $\text{MnO}_x\text{-CeO}_2$ NO_x catalysts by PVP-assisted supercritical anti-solvent (SAS) precipitation. p. 2188].

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